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the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it displays a valid OMB control number. **Application Number** 10/729,511

TRANSMITTAL

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TRANSMITTAL	Filing Date	December 4, 2003	
FORM	First Named Inventor	Gregory BREYTA et al.	
(to be used for all correspondence after initial filing)	Art Unit	1713	
(to be used for all correspondence after initial ming)	Examiner Name	Unassigned	
Mail Stop	Attorney Docket Number	ARC920030073US1	

No fee due	ENCLOSURES (Check all that apply)					
Extension of Time Request Express Abandonment Request Information Disclosure Statement & Form(s) PTO-1449 Copy(ies) of cited reference(s) Certified Copy of Priority Document(s) Response to Missing Parts Incomplete Application Response to Missing Parts under 37 CFR 1.52 or 1.53 SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT Firm or Individual Name (print/type) Reed & Eberle LLP Signature CERTIFICATE OF TRANSMISSION/MAILING I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Bpx 1450, Alexandria, VA 22313-1450 on the date shown below.	Fee Transmittal Fee(s) due Fee Transmittal Check for \$* Charge any underpayment or credit any overpayment to Deposit Account No. 09-0441 Return postcard Amendment/Reply After Final	Drawing(s) Licensing-related Papers Petition Petition to Convert to a Provisional Application Power of Attorney, Revocation, Change of Correspondence Address Terminal Disclaimer Request for Refund	to a Techno Appeal Com of Appeals Appeal Com (Appeal Notice Proprietary Status Lette Other Enclo	ology Center (TC) nmunication to Board and Interferences nmunication to TC e, Brief, Reply Brief) Information er ssure(s) (please		
Firm or Individual Name (print/type) Signature Dianne E. Reed, Registration No. 31,292 Reed & Eberle LLP Date CERTIFICATE OF TRANSMISSION/MAILING I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on the date shown below.	Extension of Time Request Express Abandonment Request Information Disclosure Statement & Form(s) PTO-1449 Copy(ies) of cited reference(s) Certified Copy of Priority Document(s) Response to Missing Parts / Incomplete Application Response to Missing Parts	Remarks:				
Individual Name (print/type) Reed & Eberle LLP Date Date CERTIFICATE OF TRANSMISSION/MAILING I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on the date shown below.			AGENT			
Signature CERTIFICATE OF TRANSMISSION/MAILING I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on the date shown below.			Telephone	(659) 330-0900		
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Signature Date Will Bays	I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on the date shown below. Name (print/type) Will Says					

Atty Dkt No. ARC920030073US1 R&E No. 5075-0040

PATENT

HE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Gregory BREYTA et al.

Confirmation No.: 2373

Serial No.: 10/729,511

Group Art Unit: 1713

Filing Date: December 4, 2003

Examiner: Unassigned

Title: PRECURSORS TO FLUOROALKANOL-CONTAINING OLEFIN MONOMERS,

AND ASSOCIATED METHODS OF SYNTHESIS AND USE

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

This is an Information Disclosure Statement submitted for the Examiner's consideration. Applicants respectfully request that the Examiner review and make of record the references identified below.

A PTO-1449 form listing the references accompanies this paper. Applicants would appreciate the Examiner's initialing and returning the form to indicate that the references have been reviewed and made of record. The references are as follows:

U.S. PATENT DOCUMENT					
Document No.					
3,444,148	5/13/69	Adelman			

F	OREIGN PATENT DOCUMENTS	
Document No.	Publication Date	Country
WO 01/86352	11/15/01	PCT
WO 02/079287	10/10/02	PCT
WO 03/040827	5/15/03	PCT

NONPATENT DOCUMENTS

BAE et al. (2003), "Rejuvenation of 248 nm Resist Backbones for 157 nm Lithogrpahy," *Journal of Photopolymer Science and Technology* 14(4):613-620.

FEDYNYSHYN et al. (2001), "High Resolution Fluorocarbon Based Resist for 157-nm Lithography," Advances in Resist Technology And Processing XVIII, Proceedings of SPIE 4345:296-307.

ITO et al. (2001), "Polymer Design for 157 nm Chemically Amplified Resists," Advances In Resist Technology And Processing XVIII, Proceedings Of SPIE 4345:273-284.

KUNZ et al. (2001), "Experimental VUV Absorbance Study of Fluorine-Functionalized Polystyrenes," *Advances in Resist Technology and Processing XVIII, Proceedings of SPIE* 4345:285-295.

URRY et al. (1968), "Multiple Multicenter Reactions of Perfluoro Ketones with Olefins," *The Journal of Organic Chemistry* 33(6):2302-2310.

As the subject application was filed after June 30, 2003, a copy of U.S. Patent No. 3,444,148 disclosed in this Information Disclosure Statement is not required and, therefore, is not included.

This Information Disclosure Statement is not intended as a representation that a search has been made, that additional information material to the examination of this application does not exist, or that any of the above references constitutes prior art to the present application within the meaning of 35 USC § 102.

As applicants have not yet received a first Action on the merits, no fee is required for filing this Information Disclosure Statement. If, however, the PTO finds that for some reason a fee is found to be necessary, our Deposit Account No. 18-0580 may be charged therefor.

Respectfully submitted,

By:

Dianne E. Reed

Registration No. 31,292

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INFORMATION IN STATEMENT BY

(use as many sheets as necessary)

of

Complete if Known				
Application Number 10/729,511				
Filing Date	December 4, 2003			
First Named Inventor	Gregory BREYTA et al.			
Art Unit	1713			
Examiner Name	Unassigned			
Attorney Docket Number	ARC920030073US1			

	U.S. PATENT DOCUMENTS							
Examiner Initials*	Cite No.	Document No.	Issue Date or Publication Date	Name of Patentee or Applicant of Cited Document	Class	Subclass	Filing Date if Appropriate	
	AA	3,444,148	5/13/69	Adelman				

	FOREIGN PATENT DOCUMENTS								
Examiner Initials*	Cite No.	Foreign Patent Document No.	Publication Date	Country	Class	Subclass	Т		
	AB	WO 01/86352	11/15/01	PCT					
	AC	WO 02/079287	10/10/02	PCT					
_	AD	WO 03/040827	5/15/03	PCT					

		OTHER DOCUMENTS — NONPATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), Title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Т
	AE	BAE et al. (2003), "Rejuvenation of 248 nm Resist Backbones for 157 nm Lithogrpahy," <i>Journal of Photopolymer Science and Technology</i> 14(4):613-620.	
	AF	FEDYNYSHYN et al. (2001), "High Resolution Fluorocarbon Based Resist for 157-nm Lithography," Advances in Resist Technology And Processing XVIII, Proceedings of SPIE 4345:296-307.	
	AG	ITO et al. (2001), "Polymer Design for 157 nm Chemically Amplified Resists," Advances In Resist Technology And Processing XVIII, Proceedings Of SPIE 4345:273-284.	
	ΑН	KUNZ et al. (2001), "Experimental VUV Absorbance Study of Fluorine-Functionalized Polystyrenes," Advances in Resist Technology and Processing XVIII, Proceedings of SPIE 4345:285-295.	
	ΑI	URRY et al. (1968), "Multiple Multicenter Reactions of Perfluoro Ketones with Olefins," <i>The Journal of Organic Chemistry</i> 33(6):2302-2310.	

Examiner	Date	
Signature	 Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.